



METHOD FOR MANUFACTURING CATALYTIC OXIDE ANODE USING HIGH  
TEMPERATURE SINTERING  
(AMENDED)

BACKGROUND OF THE INVENTION

5

1. Field of the invention

The present invention relates, in general, to a method for manufacturing a catalytic oxide anode using high temperature sintering at 600°C or higher, which can increase a decomposition efficiency of an organic substance or a production of hypochlorous acid by improving a performance of the catalytic oxide anode (Ru oxide anode, Ir oxide anode) used in a water treatment, and in particular, to a method for manufacturing a catalytic oxide anode, in which the oxide anode is sintered at 600°C or higher, and a TiO<sub>2</sub>-screening layer is ~~formed~~ added between a titanium base metal and a catalytic oxide layer to prevent a lowering of the oxide anode activity owing to ~~an oxidation of the titanium base metal caused by sintering the oxide anode at high temperature and a solid diffusion of an oxide into an anode surface.~~ a solid diffusion of titanium oxide resulting from an oxidation of the titanium base metal at the high temperature into an anode surface.

10

15

2. Description of the Prior Art

Generally, when a catalytic oxide anode used in a water treatment process is manufactured, decomposition performance of an organic substance by the oxide anode as well as physical and electrochemical properties of the oxide anode should be estimated.

20

An electrochemical water treatment process using the catalytic oxide anode used in a decomposition of a ~~non-degradable~~ non-biodegradable organic substance, sterilization, and bleaching of waste water has advantages of a low temperature and a remote control process,

25

and production of ~~oxidants without chemical additives generating secondary waste~~ strong oxidants without adding chemicals generating secondary waste. The oxidant ~~by the oxide electrode~~ is active hydroxyl radicals  $\text{OH}^\cdot$   $\text{OH}^\cdot$  produced during a production of oxygen during an electrolysis reaction of water, or several chloric acid ions ~~hypochlorous acid  $\text{OCl}^-$ , chlorous acid  $\text{OCl}_2^-$ , chloric acid  $\text{OCl}_3^-$ , perchloric acid  $\text{OCl}_4^-$  owing to a production of chlorine. due to chlorine gas generation.~~

The catalytic oxide anode developed in the 1970's is referred as DSA (Dimensionally Stable Anode), and requires a relatively low overvoltage to produce oxygen evolution. ~~Poisonous organics~~ Organic fouling materials on the oxide anode surface are oxidized by various highly reactive oxygen species produced from the oxide anode surface. Furthermore, the oxide anode can convert organics in waste water into carbon dioxide and water to incinerate the organics, and also be used for a long time because the oxide anode surface is made of a kind of ceramics, in comparison with other metal electrodes. Accordingly, the oxide anode can be applied to various water treatment applications such as a decomposition of ~~a non-degradable organic substance~~ non-biodegradable substances, sterilization and bleaching of waste water.

A representative catalytic oxide anode is  $\text{RuO}_2/\text{Ti}$  or  $\text{IrO}_2/\text{Ti}$ , which is a catalytic oxide having a rutile structure.

Generally, when a catalytic oxide anode is manufactured, it is necessary to ~~measure~~ evaluate electrochemical properties such as a voltammetric charge capacity (Q) indicating a degree of activity of the oxide anode ~~[[or]]~~ and a ~~tafel~~ Tafel slope in generation of oxygen or chlorine evolution, and physical properties such as a resistance of the oxide anode surface. Variables affecting electrochemical and physical properties of the oxide anode ~~include~~ are ~~[[an]]~~ etching method of titanium base metal, ~~[[a]]~~ coating method of metal chloride which is coated on the base metal, ~~[[the]]~~ number of a coating ~~process~~ layers, and a sintering

temperature. Among the above variables, the sintering temperature is the most important, and it has been defined within a range from 400 to 550°C during the manufacture of RuO<sub>2</sub> or IrO<sub>2</sub> anodes.

The sintering temperature is defined within a range from 400 to 550°C so that the oxide anode has a sufficient anode activity, and low resistance of its surface when RuCl<sub>3</sub> or IrCl<sub>3</sub> used as a coating material of the oxide anode is converted to RuO<sub>2</sub> or IrO<sub>2</sub>. The sintering temperature for the manufacture of RuO<sub>2</sub> or IrO<sub>2</sub> anodes is known to have to be used within a range from 400 to 550°C in order for the oxide electrodes to have a sufficient electrochemical activity, and low resistance of its surface when RuCl<sub>3</sub> or IrCl<sub>3</sub> used as a coating material of the oxide anode is converted to RuO<sub>2</sub> or IrO<sub>2</sub>.

However, when the sintering temperature is higher than 550°C, the resistance of the oxide anode surface is rapidly increased and the oxide anode activity is reduced due to an oxidation of the titanium base metal. When the sintering temperature is higher than 550°C, the oxidation of the titanium base metal begins, which results in the rapid increase of resistance of the oxide anode surface and decrease of the oxide anode activity. As shown in Figs. 1 and 2, where an electric charge Q, of RuO<sub>2</sub> or IrO<sub>2</sub> anodes, and a resistance of RuO<sub>2</sub> or IrO<sub>2</sub> anodes, respectively, are measured within a range of +0.3 to +1.03 V at a scanning rate of 40 mV/sec, with regard to sintering temperatures of the anodes, voltammetric charge capacities (Q) measured within a range of +0.3 to +1.03 V at a scanning rate of 40 mV/sec and resistances of RuO<sub>2</sub> or IrO<sub>2</sub> anodes, respectively are plotted with the sintering temperature, it is apparent that the resistance of the oxide anode surface is rapidly increased and the oxide anode activity is reduced when the sintering temperature is higher than 550°C, and so the sintering temperature of the oxide anode cannot be more than 600°C in view of electrochemical and physical properties. On the other hand, when the temperature

is less than 400°C, ~~the oxide anode surface~~ the metal chloride on the titanium base metal surface is not fully converted to the oxide.

The conventional RuO<sub>2</sub> or IrO<sub>2</sub> anodes sintered at 400 to 550°C have good electrochemical properties, but do not ~~optimally decompose organic substances.~~ show the best decomposition of organic substances, as shown in Fig.3. ~~To manufacture an oxide anode with optimum performance,~~ To find the best condition for manufacture of oxide electrode, therefore, decomposition efficiency of organic substances by the oxide anode, as well as physical and electrochemical properties of the oxide anode, should be estimated together.

Thus far, there have been disclosed many prior arts for catalytic oxide anodes. However, the present invention is different from prior arts in various aspects. For example, the present invention differs from Korean Patent Publication Nos. 1982-1344, 1995-26819, 1997-10672, 2000-40399, 2000-13786, 2001-28158 in manufacturing method and sintering temperature. Being directed to Sn-coating of transition metal oxides, U. S. Pat. Nos. 5,756,207, and 5,705,265 are different from the present invention in object, manufacturing method, and sintering temperature. A difference between the present invention and U. S. Pat. No. 4,444,642 which describes a dimensionally stable coated electrode for electrolytic process, comprising a protective oxide layer on valve metal base, and process for manufacturing the same, in which the electrode is DSA, i.e. PbO<sub>2</sub>, MgO<sub>2</sub>, resides in sintering temperature. A related prior art can be found in U. S. Pat. No. 4,426,263 which disclose a method and electrocatalyst for making chlorine dioxide, in which the catalytic anode is Ru-Rh, Ru-Rh-Pb, Ru-Pb, Ir-Rh, and Ir-Pt. However, nowhere is mentioned a manufacturing method of electrodes. U. S. Pat. No. 6,103,299, which discloses a method for preparing an electrode for electrolytic processes, in which an oxide comprises Ti, Ta, and Nb chlorides, is related to, but apparently different from the present invention.

Furthermore, according to C. Comninellis, G.P. Vercesi ~~J. Appl. Electrochem., Vol.21, 335(1991)~~, an oxide anode should be sintered at 560°C or lower because an oxide film causes a problem of reduced conductivity when the oxide anode is sintered at 560°C or higher. And also, there are disclosed oxide anodes sintered at 600°C or lower according to J.M. Eugene et al. ~~J. Electrochem. Soc., Vol.136(9), 2596(1989)~~. In addition, when the RuO<sub>2</sub> or IrO<sub>2</sub> oxide anode is manufactured, the oxide anode is sintered at 600°C or lower according to S. Trasatti ~~Electrochimica Acta, Vol.29, 1504(1984)~~, C. Comniellis ~~Electrochimica Acta, Vol.39, 1857(1994)~~, J.F.C. Boodts, S. Trasatti ~~J. Electrochem. Soc., Vol.137, 3784(1990)~~, A.D. Battisti, G. Lodi, M. Cappadonia, G. Bataglin, R. Kotz ~~J. Electrochem., Soc., Vol.136(9), 2596(1989)~~, J. Krysa, L. Kule, R. Mraz, I. Rousar ~~J. Appl. Electrochem., Vol.26, 1996(1996)~~, L.D. Silva, V.A. Alves, M.A.P.da Silva, S. Trasatti, J.F.C. Boots ~~Can. J. Chem., Vol.75, 1483(1997)~~, R. Kotz, H.J. Lewerenz, S. Stucki ~~J. Electrochem. Soc., Vol.130, 825(1983)~~, A.S. Pilla, E.O. Cobo, M.M. Duarte, D.R. Salinas ~~J. Appl. Electrochem., Vol.27, 1283(1997)~~, C. Comninellis, G.P. Vercesi ~~J. Appl. Electrochem., Vol.21, 335(1991)~~, T.A.F. Lassa;l, L.O.S. Bulhoes, L.M.C. Abeid, J.F.C. Boodts ~~J. Electrochem. Soc., Vol.144(10), 3348(1997)~~.

## SUMMARY OF THE INVENTION

It is therefore an object of the present invention to avoid disadvantages of a conventional catalytic oxide anode, and to provide a method for manufacturing a catalytic oxide anode sintered at high temperature, which can increase a decomposition efficiency of an organic substance by the oxide anode and a production rate of active chloric acid ions with about the same electric power consumption rate as the conventional anode in water treatment applications using electrolysis, such as, sterilization and bleaching of waste water, and oxidization of organic substances.

To accomplish the above object, the present invention provides a method for manufacturing a catalytic oxide anode, in which the catalytic oxide anode is sintered at 600°C or higher, and a TiO<sub>2</sub>-screening layer, i.e. a valve metal oxide layer for suppressing a lowering of the oxide anode activity owing to an oxidation of the titanium base metal caused by sintering the oxide anode at high temperature and a solid diffusion of ~~[[an]]~~ the titanium oxide into an anode surface, is ~~formed~~ added between a titanium base metal and ~~[[an]]~~ the Ru or Ir oxide layer of the oxide anode surface, with estimation of decomposition properties of an organic substance by the oxide anode as well as physical and electrochemical properties of the oxide anode.

#### BRIEF DESCRIPTION OF THE DRAWINGS

The above and other objects, features and other advantages of the present invention will be more clearly understood from the following detailed description taken in conjunction with the accompanying drawings, in which:

Fig. 1 is a graph illustrating the effect of ~~a-varying~~ the sintering temperature on an ~~active electric charge~~ voltammetric charge capacities (Q) ~~[[in]]~~ of conventional RuO<sub>2</sub> and IrO<sub>2</sub> oxide anode surfaces;

Fig. 2 is a graph illustrating the effect of ~~a-varying~~ the sintering temperature on resistance of ~~conventional~~ RuO<sub>2</sub> and IrO<sub>2</sub> oxide anode surfaces;

Fig. 3 is a graph illustrating the effect of a varying sintering temperature on a decomposition rate yield of 4CP by RuO<sub>2</sub> and IrO<sub>2</sub> oxide anodes;

Fig. 4 is a graph illustrating the effect of ~~a-varying~~ the sintering temperature on a decomposition rate yield of 4CP by RuO<sub>2</sub> and IrO<sub>2</sub> oxide anodes with TiO<sub>2</sub>-screening layer;

~~Fig. 5 is a graph illustrating the effect of a  $\text{TiO}_2$ -screening layer on the relative concentrations of titanium, iridium, and oxygen measured by AES (Auger Electron Spectroscopy: VG Microlab 300R) in the surface of  $\text{IrO}_2$  anode;~~

Fig. 5 is a graph illustrating the relative concentrations profile of titanium, iridium, and oxygen components within Ir oxide layer on the Ti base metal electrode to see the effect of a  $\text{TiO}_2$ -screening layer measured by AES (Auger Electron Spectroscopy: VG Microlab 300R);

Fig. 6 is a graph illustrating a reduction rate of chlorine ions in an aqueous solution and a production rate of active chloric acid when  $\text{RuO}_2$  anode of the present invention is used;

Fig. 7 is a graph illustrating a reduction rate of chlorine ions in an aqueous solution and a production rate of active chloric acid when  $\text{IrO}_2$  anode of the present invention is used.

#### DETAILED DESCRIPTION OF THE INVENTION

The present invention provides a method for manufacturing a catalytic oxide anode of  $\text{RuO}_2$  or  $\text{IrO}_2$  using high temperature sintering, wherein a titanium base metal is etched with hydrochloric acid, followed by being coated with a precursor solution of  $\text{RuCl}_3$  or ~~chlorides of~~  $\text{IrO}_3$   $\text{IrCl}_3$  in hydrochloric acid according to a brushing or dipping method, and then the resulting material is dried at  $60^\circ\text{C}$  for 10 min, thermally treated at  $250$  to  $350^\circ\text{C}$  for 10 min, and finally sintered at  $600$  to  $700^\circ\text{C}$  for 1 to 2 hours.

Furthermore, the present invention provides a method for manufacturing a catalytic oxide anode, wherein a  $\text{TiO}_2$ -screening layer is ~~formed~~ added between a titanium support and a surface of the oxide anode between the titanium base metal and the final catalytic oxide layer, the titanium base metal having  $\text{TiO}_2$ -screening layer being, coated with a precursor solution of  $\text{RuCl}_3$  or ~~chlorides of~~  $[[\text{IrO}_3]]$   $\text{IrCl}_3$  in hydrochloric acid according to a brushing or dipping method, dried at  $60^\circ\text{C}$  for 10 min, thermally treated at  $250$  to  $350^\circ\text{C}$  for 10 min, and

finally sintered at 600 to 700°C for 1 to 2 hours, the TiO<sub>2</sub>-screening layer serving as an valve metal oxide for preventing the activity of the anode from being lowered owing to the oxidation of a titanium base metal caused upon sintering of the anode at high temperature and the solid diffusion of an oxide into the anode surface, the valve metal oxide being selected from the group consisting of TiO<sub>2</sub>, SnO<sub>2</sub>, RuO<sub>2</sub>, and IrO<sub>2</sub> sintered at 450 to 550°C.

In more detail, the titanium base metal is cleaned with a cleaning solution in an ultrasonic cleaner at 80°C for 30 min, and then degreased and cleaned with a solvent, i.e. trichloroethylene for 24 hours or more, followed by being etched with 10 to 35 % HCl at 40 to 60°C for a certain period of time. After being rinsed with an ultra-pure water, the etched titanium base metal is coated with 0.2 M RuCl<sub>3</sub> or a solution of 1:1 IrO<sub>3</sub>: hydrochloric acid (v/v) by brushing or dipping. a precursor solution of 0.2 M RuCl<sub>3</sub> or IrCl<sub>3</sub> dissolved in 1:1 v/o hydrochloric acid by brushing or dipping.

After that, the resulting titanium metal is dried at 60°C for 10 min and then sintered at 250 to 350°C for 10 min, repeatedly, to ~~form~~ obtain the desired number of ~~coats~~ coating layers, followed by being sintered at 600 to 700°C for 1 to 2 hours, thereby the catalytic oxide anode having an improved performance is manufactured. To prevent a lowering of the anode activity owing to an oxidation of a titanium base metal caused by sintering the anode at high temperature and a solid diffusion of an oxide the titanium oxide into an anode surface, a valve metal oxide layer, i.e. TiO<sub>2</sub>-screening layer, is ~~formed~~ added ~~between the titanium base metal and an oxide layer of the anode surface~~ between a titanium base metal and a catalytic oxide layer.

According to the present invention, a decomposition efficiency of organic substances by the oxide anode is increased by 50 to 100 % because the oxide anode is manufactured at 600 to 700°C, which is higher than a conventional sintering temperature range for manufacturing RuO<sub>2</sub> or IrO<sub>2</sub> anode, i.e. 400 to 550°C, by 100°C or higher, thereby the



performance of the catalytic oxide anode is improved. With reference to Fig. 3 illustrating the effect of a varying sintering temperature on a decomposition ~~rate~~ yield of 4CP by RuO<sub>2</sub> and IrO<sub>2</sub> oxide anodes, the organic substance, i.e. 4-chlorophenol, is most actively decomposed at 600 to 700°C, not at 400 to 550°C.

5 As described above, the reason why the decomposition efficiency of the organic substance is increased is that active sites producing reactive oxygen species or chlorine are insufficient in number because metallic chlorides in a coating solution on the titanium base metal are not fully converted to metallic oxides when the oxide anode is sintered at the conventional sintering temperature, and reactive oxygen species or chlorine with a higher  
10 reactivity are produced from the surface of the oxide anode sintered at higher temperature than the conventional sintering temperature to more actively decompose organic substances.

According to the present invention, however, there is a problem that an activity of the oxide anode is reduced and a resistance of the oxide anode surface is increased because the titanium base metal is oxidized and ~~[[an]] the oxide of titanium is diffused~~ diffuses into the  
15 surface layer of the oxide anode, i.e. Ir or Ru oxide layer, when the oxide anode is sintered at 600°C or higher. To avoid the above problem, it is necessary to form a different metal oxide layer (TiO<sub>2</sub>, SnO<sub>2</sub>, RuO<sub>2</sub>, IrO<sub>2</sub>) sintered at 450 to 550°C, i.e. the TiO<sub>2</sub>-screening layer for suppressing a production of TiO<sub>2</sub> owing to ~~[[an]] the~~ the oxidation of the titanium base metal and ~~[[a]] its~~ its solid diffusion, between the titanium base metal and the oxide layer of the oxide anode  
20 surface.

With reference to Fig. 4, the oxide anode with the TiO<sub>2</sub>-screening layer sintered at 650°C increases a decomposition ~~rate~~ yield of 4CP.

In comparison with an oxide anode sintered at the conventional sintering temperature, the oxide anode with the TiO<sub>2</sub>-screening layer sintered at 600°C or higher improves the  
25 decomposition rate of the organic substance. For example, the decomposition rate is

increased by 70 % for RuO<sub>2</sub> anode, and by 250 % or more for IrO<sub>2</sub> anode. Referring to Fig. 5, there is illustrated the effect of the TiO<sub>2</sub>-screening layer on the relative concentrations concentration profile of titanium, iridium, and oxygen measured by AES in the surface of IrO<sub>2</sub> anode. The extent to which the TiO<sub>2</sub>-screening layer suppresses solid diffusion of TiO<sub>2</sub> into the IrO<sub>2</sub> anode surface, owing to an oxidation of the titanium base metal, is measured by AES.

When the Ir oxide anode is sintered at 650°C without the TiO<sub>2</sub>-screening layer, a concentration of titanium around within an oxide layer of the oxide anode surface is higher than that of iridium because the titanium base metal is oxidized and the TiO<sub>2</sub> is fully diffused into the surface of the oxide anode. On the other hand, when the Ir oxide anode is sintered at 650°C with the TiO<sub>2</sub>-screening layer, the concentration of iridium is higher than that of titanium because the diffusion is suppressed. These phenomena are equally true of RuO<sub>2</sub> anode.

With reference to Fig. 2, a resistance of iridium oxide surface sintered at 650°C without the TiO<sub>2</sub>-screening layer is about 100 Ωcm, but iridium oxide sintered at 650°C with the TiO<sub>2</sub>-screening layer has a reduced surface resistance of 10 Ωcm or less. As apparent from the above description, it can be seen that a production of TiO<sub>2</sub> owing to an oxidation of the titanium base metal largely affects the resistance of the oxide anode surface, and the TiO<sub>2</sub>-screening layer greatly reduces an amount of TiO<sub>2</sub> existing on the anode surface sintered at high temperature.

When the sintering temperature of RuO<sub>2</sub> or IrO<sub>2</sub> anode is increased, an electric power consumption rate of RuO<sub>2</sub> or IrO<sub>2</sub> anode sintered at 650°C is not greatly increased during the decomposition of organic substance, although the resistance of the oxide anode surface is greatly increased from 550°C, as shown in Fig. 2, but the electric power consumption rate of the RuO<sub>2</sub> or IrO<sub>2</sub> oxide anode is almost identical to that of the oxide anode sintered at 400 to 550°C - the difference is only 2 to 3 %.

As described above, the reason why the electric power consumption rates between two anodes sintered at different temperatures are almost identical is that a physical resistance of the catalytic oxide anode surface does not greatly affect an electric conductivity of a real anode surface, due to interaction between ions in a real solution during the electrolysis reaction.

Accordingly, the oxide anode with the  $\text{TiO}_2$ -screening layer of the present invention greatly increases a decomposition rate of an organic substance without additional electric power consumption.

Referring to Figs. 6 and 7, a concentration of free residual chlorine ( $\text{Cl}_2$ ,  $\text{HOCl}$ ,  $\text{OCl}^-$ ) is plotted to estimate a production rate of chloric acid ions having a high oxidizing power and bactericidal activity, by  $\text{IrO}_2$  or  $\text{RuO}_2$  anode sintered at high temperature. As apparent from the result shown in Figs. 6 and 7, it can be seen that a reduction rate of chlorine ion in a solution and a production rate of chloric acid ions by the oxide anode according to the present invention are faster in comparison with the conventional oxide anode.

As described above, the present invention has advantages in that a catalytic oxide anode such as  $\text{RuO}_2$  or  $\text{IrO}_2$  anode increases a decomposition efficiency of organic substances and a production rate of active chloric acid ions without additional electric power consumption in water treatment applications using an electrolysis reaction, such as sterilization and bleaching of waste water, and oxidization of an organic substance.

The present invention has been described in an illustrative manner, and it is to be understood that the terminology used is intended to be in the nature of description rather than of limitation. Many modifications and variations of the present invention are possible in light of the above teachings. Therefore, it is to be understood that within the scope of the appended claims, the invention may be practiced otherwise than as specifically described.

What is claimed is:

1. A method for manufacturing a catalytic oxide anode of

RuO<sub>2</sub> or IrO<sub>2</sub> using high temperature sintering, wherein a titanium base metal is etched with hydrochloric acid, followed by being coated with a precursor solution of RuCl<sub>3</sub> or ~~chlorides of IrO<sub>3</sub>~~ IrCl<sub>3</sub> in hydrochloric acid according to a brushing or dipping method, and then the resulting material is dried at 60°C for 10 min, thermally treated at 250 to 350°C for 10 min, and finally sintered at 600 to 700°C for 1 to 2 hours.

2. A method for manufacturing a catalytic oxide anode using high temperature

sintering, wherein a TiO<sub>2</sub>-screening layer (a different metal oxide layer (TiO<sub>2</sub>, SnO<sub>2</sub>, RuO<sub>2</sub>, IrO<sub>2</sub>) sintered at 450 to 550°C), is ~~formed~~ added between a titanium support and a surface of the oxide anode, ~~coated with a solution of RuCl<sub>3</sub> or chlorides of IrO<sub>3</sub> in hydrochloric acid~~ coated with a precursor solution of RuCl<sub>3</sub> or IrCl<sub>3</sub> in hydrochloric acid according to a brushing or dipping method, dried at 60°C for 10 min, thermally treated at 250 to 350°C for 10 min, and finally sintered at 600 to 700°C for 1 to 2 hours, said TiO<sub>2</sub>-screening layer serving as an valve metal oxide for preventing the activity of the anode from being lowered owing to the oxidation of a titanium base metal caused upon sintering of the anode at high temperature and the solid diffusion of an oxide into the anode surface, said valve metal oxide being selected from the group consisting of TiO<sub>2</sub>, SnO<sub>2</sub>, RuO<sub>2</sub>, and IrO<sub>2</sub> sintered at 450 to 550°C.

## ABSTRACT

Disclosed is a method for manufacturing a catalytic oxide anode using high temperature sintering, which can increase a decomposition efficiency of an organic substance by improving a performance of the catalytic oxide anode (Ru oxide anode, Ir oxide anode) used in a water treatment, and in particular, to a method for manufacturing a catalytic oxide anode, in which the oxide anode is sintered at 600°C or higher, and a TiO<sub>2</sub>-screening layer is ~~formed~~ added between a titanium base metal and a catalytic oxide layer to prevent a lowering of the oxide anode activity owing to an oxidation of the titanium base metal caused by sintering the oxide anode at high temperature and a solid diffusion of an oxide into an anode surface. The method for manufacturing the catalytic oxide anode is characterized in that the titanium base metal is etched with hydrochloric acid, followed by being coated with a solution of RuCl<sub>3</sub> or chlorides of IrO<sub>3</sub> in hydrochloric acid according to a brushing or dipping method, and then the resulting material is dried at 60°C for 10 min, thermally treated at 250 to 350°C for 10 min, and finally sintered at 600 to 700°C for 1 to 2 hours.